Title: METHOD OF SELECTIVE REMOVAL OF SiGE ALLOYS

Inventors: Hammond et al.
Express Mail Label No. EV334229294US
Atty Docket No.: ASC-057C1
Attorney for Applicants: Mark L. Beloborodov
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10 4

> E Si LAP Sibe E Si relaxed sibe Si Substrate -12

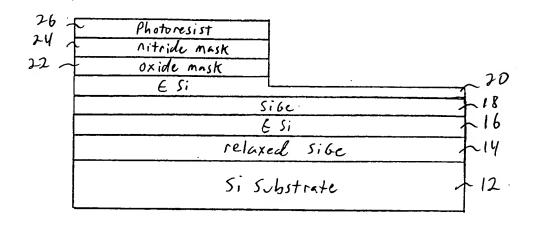
F16.1

	Photo resist	
	nitride mask	
	Oxide Mask	
	E Si CAP	
	Sibe	
	& Si	•
	relaxed sibe	
	Si Substrate	

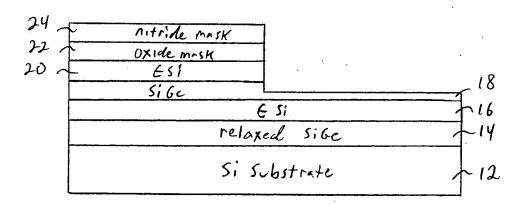
F16.2

Title: METHOD OF SELECTIVE REMOVAL OF SIGE

ALLOYS
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F16.3



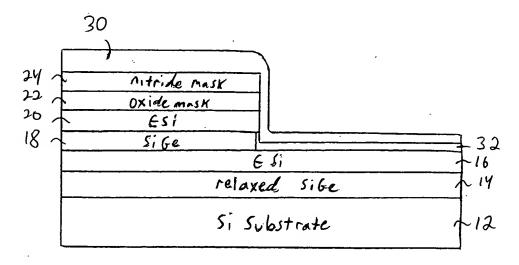
F16.4

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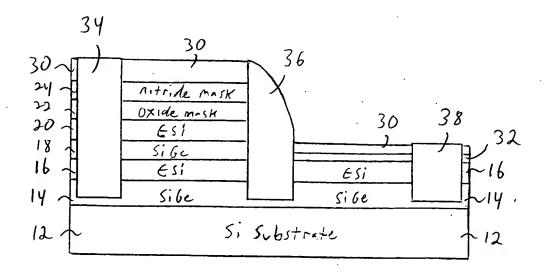
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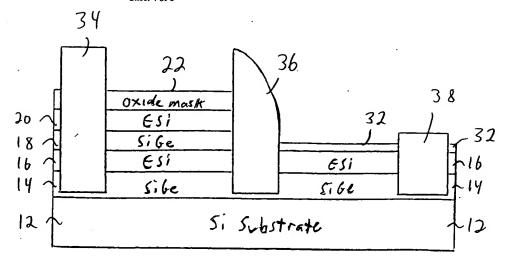


F16.5

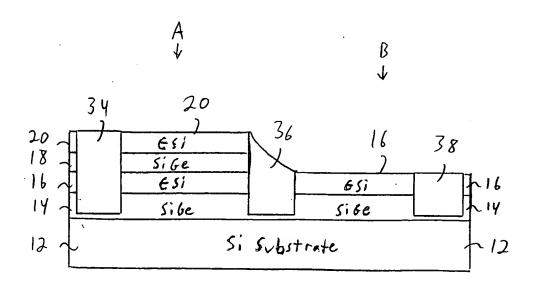


F16.6

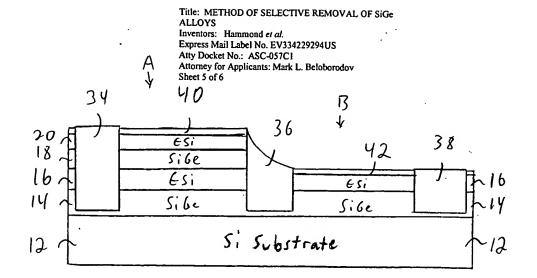
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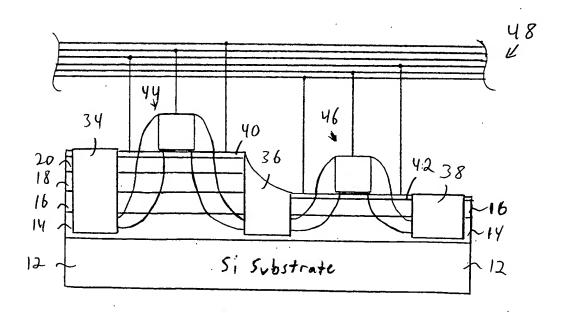
F16.7



F16.8



F16.9

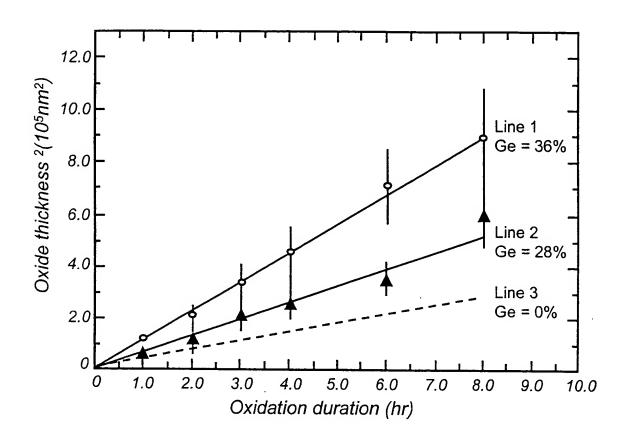


F16.10

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F16.11